Roadmap of future devices and related cleaning challenges/opportunities

P.W. Mertens¹ ¹IMEC, vzw Kapeldreef 75, 3001 Leuven, Belgium

Abstract

This keynote (or opening) presentation will overview some of hot topics such as clening and surface conditioning of Fin FET or 3D structures, high mobility substrates, towards 1X nm structures/particles.